



Chemical Process Design, Simulation and Optimization

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Deadline for manuscript
submissions:

closed (31 December 2020)

Message from the Guest Editors

Topics include, but are not limited to applications in the following areas:

- Design and simulation of a novel or revamped chemical process
- Optimization of the processing capacity and operating conditions of a current chemical process
- Improvement of equipment design and the performance of a specific chemical process
- Monitoring safety and operational issues in chemical plants
- Identification of energy savings opportunities, material integration and economic evaluation to realize savings in the process design
- Development of efficient numerical and optimization methods with applications in chemical and energy engineering





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Message from the Editor-in-Chief

Processes (ISSN 2227-9717) provides an advanced forum for process/system-related research in chemistry, biology, material, energy, environment, food, pharmaceutical, manufacturing and allied engineering fields. The journal publishes regular research papers, communications, letters, short notes and reviews. Our aim is to encourage researchers to publish their experimental, theoretical and computational results in as much detail as necessary. There is no restriction on paper length or number of figures and tables.

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